

Notice of References Cited		Application/Control No. 10/725,400	Applicant(s)/Patent Under Reexamination PEREZ ET AL.	
		Examiner Bernard E Souw	Art Unit 2881	Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	A	US-5,107,221	04-1992	N'Guyen et al.	315/500
*	B	US-6,635,871	10-2003	Xu et al.	250/306
*	C	US-6,630,666	10-2003	Greaves, Roderick G.	250/308
*	D	US-2002/0030160	03-2002	Greaves, Roderick G.	250/308
*	E	US-5,159,195	10-1992	Van House, James C.	250/309
*	F	US-4,864,131	09-1989	Rich et al.	250/308
*	G	US-5,063,293	11-1991	Rich et al.	250/308
	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	O					
	P					
	Q					
	R					
	S					
	T					

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
*	U	"The LLNL Electron-Positron Beam Facility", http://www-pat.llnl.gov/H-Div/Positrons/PositronFacility.html
*	V	van Veen et al., Appl. Surf. Dci. 116 (1997) 39-44
*	W	Weng et al., Appl. Surf. Sci. 194 (2002) 24-28
*	X	Baier et al., Phys. Rev. ST Accel. Beams 5, 121001 (2002)

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.